

Image



03500.010530.5

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
KIYOFUMI SAKAGUCHI, ET AL.)	Examiner: G. Fourson, III
Appln. No.: 10/085,046)	Group Art Unit: 2823
Filed: March 1, 2002)	
For: PROCESS FOR PRODUCTION OF SEMICONDUCTOR SUBSTRATE)	
	:	October 21, 2003

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SECOND INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Copies of the listed documents are also enclosed.

REMARKS

Applicants respectfully note that Japanese Laid-Open Patent Application No. 5-217827 ("JP '827") was cited in the examination of Japanese Patent Application No. 7-45441, a priority application of the subject application. Applicants respectfully submit that EP 0 553 859, which was cited in the September 6, 2002, Information Disclosure Statement, corresponds to JP '827.

Applicants respectfully submit that Japanese Laid-Open Patent Application No. 5-217981 ("JP '981") discloses, e.g., that after H₂ annealing a porous layer, epitaxial growing is carried out. Applicants respectfully submit that EP 0 553 861 corresponds to JP '981.

Abstracts for each Japanese document are also enclosed.

FORMAL MATTERS

No fee is believed due; however, any fee required in connection with this paper should be charged to Deposit Account 06-1205. A duplicate of this paper is enclosed.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

A handwritten signature in black ink, reading "Daniel Glueck". The signature is written in a cursive, flowing style.

Attorney for Applicants
Daniel S. Glueck
Registration No. 37,838

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3800
Facsimile: (212) 218-2200

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FORM PTO 1449 (<i>modified</i>) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary) Submitted: October 21, 2003			ATTY DOCKET NO. 03500.0105305		APPLICATION NO. 10/085,046	
			APPLICANT KIYOFUMI SAKAGUCHI, ET AL.			
			FILING DATE March 1, 2002		GROUP 2823	

U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	

FOREIGN PATENT DOCUMENTS							
DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT		
5-217981	8/27/93	Japan			Abstract		
5-217827	8/27/93	Japan			Abstract		
0 553 861 A1	8/04/93	Europe					

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)		

EXAMINER	DATE CONSIDERED
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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